

Esec 2100 hS^{ix}



The New Generation High Speed Die Bonder

The Esec 2100 hS^{ix} is the latest member of the 2100ⁱ Die Bonder family. It is optimized for highest speed and scratch-free transport thanks to the easy-to-use motorized and programmable rail strip handler.

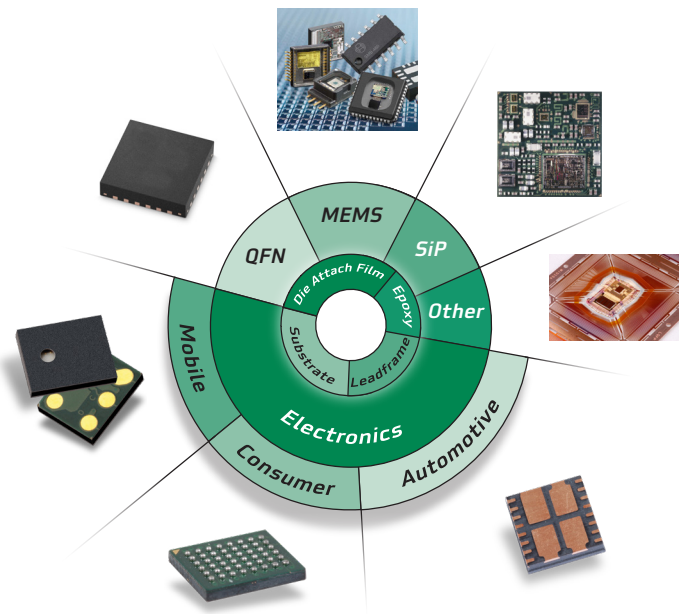
It also incorporates the proven features of the 2100ⁱ generation, such as the High Resolution Vision Systems and the Dual Dispensing Module.

The Esec 2100 hS^{ix} is the new generation High Speed Die Bonder providing now the best Cost of Ownership (CoO).

Process Quality at Even Higher Speed

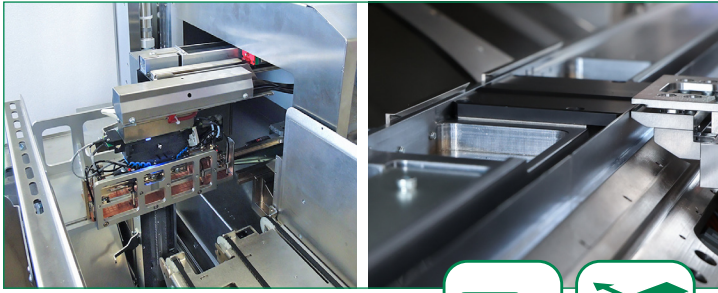
- Productivity up to 18500 UPH
- High speed soft pick and bond processes
- Motorized and programmable rail strip handler
- Dual Dispensing Module with independent writing axes
- High Resolution Vision System with Up Looking Vision Option
- Low Contrast Kit enables the vision to detect almost anything

Future Proof Equipment



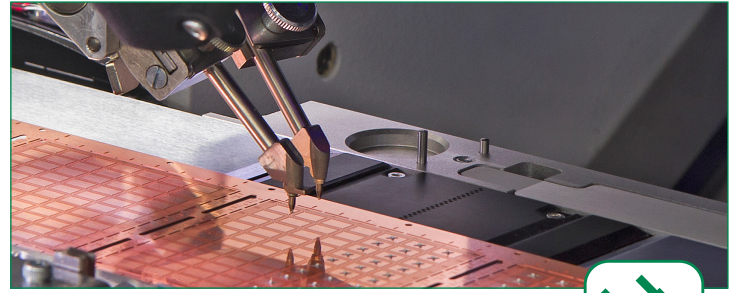


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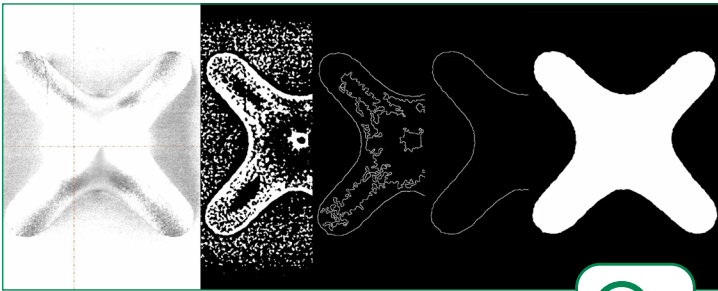
New Generation Designs

- High Resolution 4 mega pixel Vision Systems
- Motorized and Programmable Rail Strip Handler with three clamps, optimized for scratch free production
- New reliable Strip push out to Magazine by Clamp
- New Dual Universal Top Stack and Magazine Input Handler
- New All-in-One Expansion unit for all frame sizes



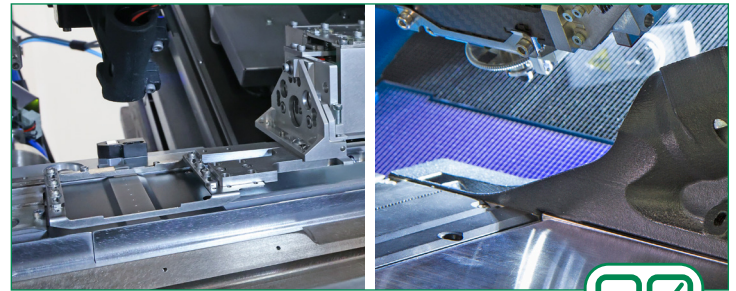
Optimized Productivity

- Motorized Rail Strip Handler allowing working position as close to Wafer as possible
- Superior and proven P&P design with High Performance P&P Y-axis and speed optimized trajectories
- Speed Optimized Soft Pick and Bond Processes
- Dual 5bar Pneumatic Dispense System with independent writing axis and pressure control



Optimized Process Control

- High Accuracy Production Modes
- Low Contrast Object detection vision capability
- Up to three calibrated Dual Color Light Sources per camera
- Full High Definition (FHD) Graphical User Interface with multiple camera inspection images and Viewers



New Generation Options

- Speed optimized Pneumatic Downholder System
- High Precision Bond Head with highly accurate Theta Axis
- High Accuracy closed loop P&P Z Axis
- New High Resolution Up looking Vision System
- Automatic Tool Setups and Optimizations

Machine Dimensions

- Footprint: W x D x H: 1785 x 1448 x 1400 mm
- Weight: approx. 1400 kg

Supply Requirements

- Voltage: 208 - 230 VAC (@ 47 - 63 Hz)
- Power rating: 800 - 1100 VA
- Compressed air: min. 5.2 bar
- Vacuum: min. -0.75 bar
- Nitrogen blow: 1.8 - 6 bar

Wafer and Die Dimensions

- Wafer size: 4" - 12"
- Frame size: 8" - 12"
- Die size*: 0.15 - 8 mm
- Die thickness: > 0.075 mm

Leadframe Size

- Width (standard): 58 - 102 mm
- Width (with narrow kit*): 23 - 67 mm
- Length: 90 - 300 mm
- Thickness: 0.1 - 0.5 mm

Process

- Bond force: 0.2 - 10 N
- Bond rotation: 360°
- Bond heating: programmable, max. 170°C (simple DAF only)

Die Placement Accuracy

- >2 mm: 18 µm / 0.2° (3σ) (high speed mode)
- >2 mm: 12 µm / 0.2° (3σ) (accuracy mode)
- >2 mm: 10 µm / 0.15° (3σ) (up looking vision)
- 0.5 - 2 mm: 20 µm / 1.0° (3σ)
- MTBF: >200 h

* Option or accessory may be required.